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Based on the authors' text *Statistical Methods for Reliability Data*, John Wiley & Sons Inc. 1998.

January 5, 2006  
19h 16min

- Describe and illustrate nonparametric and graphical methods of analyzing and presenting accelerated life test data.
- Describe and illustrate maximum likelihood methods of analyzing and making inferences from accelerated life test data.
- Illustrate different kinds of data and ALT models.
- Discuss some specialized applications of accelerated testing.
- Describe pitfalls in accelerated testing.

Example: Temperature-Accelerated Life Test on Device-A (from Hooper and Amster 1990)

**Data:** Singly right censored observations from a temperature-accelerated life test.

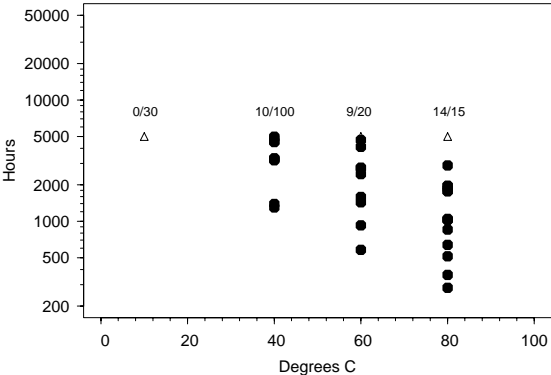
**Purpose:** To determine if the device would meet its hazard function objective at 10,000 and 30,000 hours at operating temperature of 10°C.

We will show how to fit an accelerated life regression model to these data to answer this and other questions.

Hours Versus Temperature Data from a Temperature-Accelerated Life Test on Device-A

Hours	Status	Number of Devices	Temperature °C	In Subexperiment Units	Failures
5000	Censored	30	10	30	0/30
1298	Failed	1	40	100	10/100
1390	Failed	1	40		
⋮	⋮	⋮	⋮		
5000	Censored	90	40		
581	Failed		60	20	9/20
925	Failed		60		
1432	Failed		60		
⋮	⋮	⋮	⋮		
5000	Censored	11	60		
283	Failed	1	80	15	14/15
361	Failed	1	80		
515	Failed	1	80		
638	Failed	1	80		
⋮	⋮	⋮	⋮		
5000	Censored	1	80		

Device-A Hours Versus Temperature (Hooper and Amster 1990)



ALT Data Plot

- Examine a scatter plot of lifetime versus stress data.
  - Use different symbols for censored observations.
- Note:** Heavy censoring makes it difficult to identify the form of the life/stress relationship from this plot.

### Strategy for Analyzing ALT Data

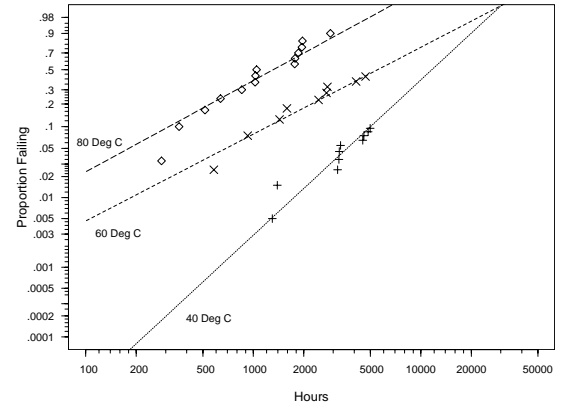
For ALT data consisting of a number of subexperiments, each having been run at a particular set of conditions:

- Examine the data graphically: Scatter and probability plots.
- Use a multiple probability plot to study the data from the individual subexperiments.
- Fit an overall model involving a life/stress relationship.
- Perform residual analysis and other diagnostic checks.
- Perform a sensitivity analysis.
- Assess the reasonableness of using the ALT data to make the desired inferences.

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### Weibull Multiple Probability Plot Giving Individual Weibull Fits to Each Level of Temperature for Device-A ALT Data

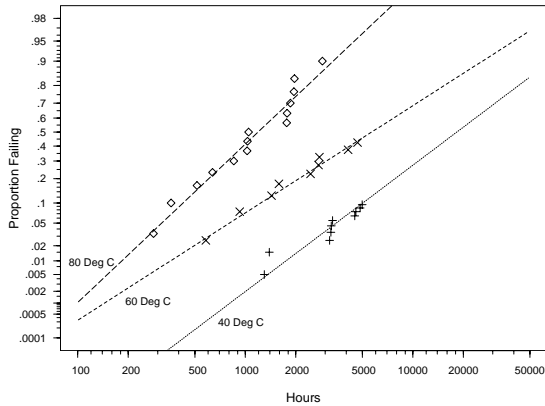
$$\widehat{\Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{sev}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right], \quad i = 40, 60, 80$$



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### Lognormal Multiple Probability Plot Giving Individual Lognormal Fits to Each Level of Temperature for Device-A ALT Data

$$\widehat{\Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right], \quad i = 40, 60, 80$$



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### ALT Multiple Probability Plot of Nonparametric Estimates at Individual Levels of Accelerating Variable

- Compute nonparametric estimates  $\hat{F}$  for each level of accelerating variable; plot on a single probability plot.
- Try to identify a distributional model that fits the data well at all of the stress-levels.

**Note:** Either the lognormal or the Weibull distribution model provides a reasonable description for the device-A data. But the lognormal distribution provides a better fit to the individual subexperiments.

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### ALT Multiple Probability Plot of ML Estimates at Individual Levels of Accelerating Variable

- For each **individual** level of accelerating variable compute the ML estimates.

Let  $T_i$  be the failure time at temperature  $\text{Temp}_i$ . For the **lognormal**,  $T_i \sim \text{LOGNOR}(\mu_i, \sigma_i)$ , assumed model:

- Compute ML estimates  $(\hat{\mu}_i, \hat{\sigma}_i)$ .
- Plot the  $\text{LOGNOR}(\hat{\mu}_i, \hat{\sigma}_i)$  cdfs on same plot.
- Assess the commonly used assumption that  $\sigma_i$  does not depend on  $\text{Temp}_i$  and that  $\text{Temp}_i$  only affects  $\mu_i$ .

**Note:** There are some small differences among the slopes that could be due to sampling error.

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### Device-A ALT Lognormal ML Estimation Results at Individual Temperatures

Parameter	ML Estimate	Standard Error	95% Approximate Confidence Interval	
			Lower	Upper
40°C $\mu$	9.81	.42	8.9	10.6
	$\sigma$	1.0	.27	1.72
60°C $\mu$	8.64	.35	8.0	9.3
	$\sigma$	1.19	.32	2.0
80°C $\mu$	7.08	.21	6.7	7.5
	$\sigma$	.80	.16	1.17

The individual loglikelihoods were  $\mathcal{L}_{40} = -115.46$ ,  $\mathcal{L}_{60} = -89.72$ , and  $\mathcal{L}_{80} = -115.58$ . The confidence intervals are based on the normal approximation method.

19 - 12

### The Arrhenius-Lognormal Regression Model

The Arrhenius-lognormal regression model is

$$\Pr[T(\text{temp}) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \mu(x)}{\sigma} \right]$$

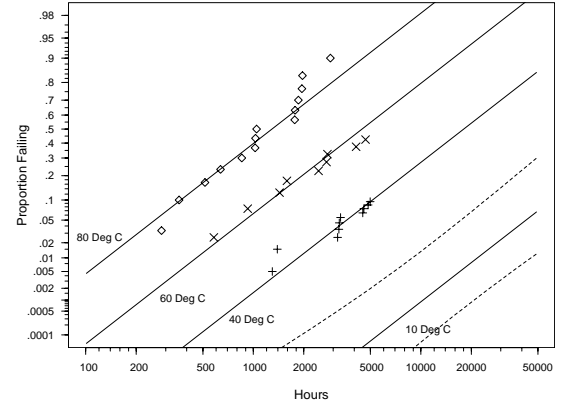
where

- $\mu(x) = \beta_0 + \beta_1 x$ ,
- $x = 11605/(\text{temp K}) = 11605/(\text{temp } ^\circ\text{C} + 273.15)$ ,
- $\beta_1 = E_a$  is the activation energy, and
- $\sigma$  assumed to be constant.

19 - 13

### Lognormal Multiple Probability Plot of the Arrhenius-Lognormal Log-Linear Regression Model Fit to the Device-A ALT Data

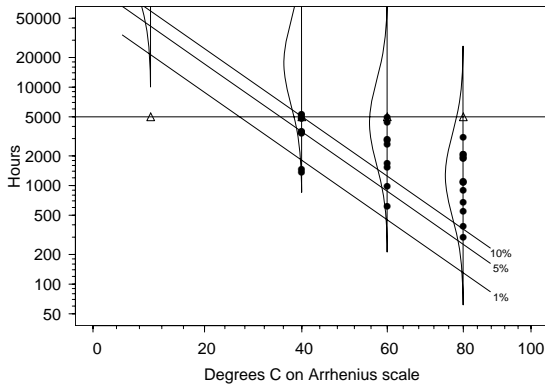
$$\hat{\Pr}[T(\text{temp}) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}(x)}{\hat{\sigma}} \right], \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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### Scatter plot showing the Arrhenius-Lognormal Log-Linear Regression Model Fit to the Device-A ALT Data

$$\log[\hat{t}_p(x)] = \hat{\mu}(x) + \Phi_{\text{nor}}^{-1}(p)\hat{\sigma}, \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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### ML Estimation Results for the Device-A ALT Data and the Arrhenius-Lognormal Regression Model

Parameter	ML Estimate	Standard Error	95% Approximate Confidence Intervals	
			Lower	Upper
$\beta_0$	-13.5	2.9	-19.1	-7.8
$\beta_1$	.63	.08	.47	.79
$\sigma$	.98	.13	.75	1.28

The loglikelihood is  $\mathcal{L} = -321.7$ . The confidence intervals are based on the normal approximation method.

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### Analytical Comparison of Individual and Arrhenius-Lognormal Model ML Estimates of Device-A Data

- Distributions fit to individual levels of temperature can be viewed as an **unconstrained model**.
- The Arrhenius-lognormal regression model can be viewed as a **constrained model** ( $\mu$  linear in  $x$  and  $\sigma$  constant).
- Use likelihood ratio test to check for lack of fit with respect to the constraints.

$$\begin{aligned} \mathcal{L}_{\text{unconst}} &= \mathcal{L}_{40} + \mathcal{L}_{60} + \mathcal{L}_{80} = -320.76 \\ \mathcal{L}_{\text{const}} &= -321.7 \end{aligned}$$

- $-2(\mathcal{L}_{\text{const}} - \mathcal{L}_{\text{unconst}}) = -2(-321.7 + 320.76) = 1.88 < \chi_{(.75,3)}^2 = 4.1$ , indicating that there is no evidence of inadequacy of the constrained model, relative to the unconstrained model.

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### ALT Multiple Probability Plot of ML Estimates with an Assumed Life/Stress Relationship

- To make inferences at levels of accelerating variable not used in the ALT, use a life/stress relationship to fit all the data.

Let  $T(x_i)$  be the failure time at  $x_i = 11605/(\text{Temp}_i + 273.15)$ . For the,  $T(x_i) \sim \text{LOGNOR}(\mu(x_i) = \beta_0 + \beta_1 x_i, \sigma)$ , **lognormal SAFT** assumed model:

- Compute ML estimates  $(\hat{\beta}_0, \hat{\beta}_1, \hat{\sigma})$ .
- Plot the  $\text{LOGNOR}[\hat{\mu}(x_i) = \hat{\beta}_0 + \hat{\beta}_1 x_i, \hat{\sigma}]$  cdfs on same plot.
- Plot  $\hat{t}_p(x) = \exp[\hat{\beta}_0 + \hat{\beta}_1 x + \Phi_{\text{nor}}^{-1}(p)\hat{\sigma}]$  for various values of  $p$  and a range of values of  $x$ .

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### ML Estimation for the Device-A Lognormal Distribution $F(30,000)$ at $10^\circ\text{C}$

$$\begin{aligned}\hat{\mu}(x) &= \hat{\beta}_0 + \hat{\beta}_1 x \\ &= -13.469 + .6279 \times 11605 / (10 + 273.15) = 12.2641 \\ \hat{\zeta}_e &= [\log(t_e) - \hat{\mu}] / \hat{\sigma} = [\log(30,000) - 12.2641] / .9778 \\ &= -2.000 \\ \hat{F}(30,000) &= \Phi_{\text{nor}}(\hat{\zeta}_e) = \Phi_{\text{nor}}(-2.000) = .02281 \\ \hat{\Sigma}_{\hat{\mu}, \hat{\sigma}} &= \begin{bmatrix} \widehat{\text{Var}}(\hat{\mu}) & \widehat{\text{Cov}}(\hat{\mu}, \hat{\sigma}) \\ \widehat{\text{Cov}}(\hat{\mu}, \hat{\sigma}) & \widehat{\text{Var}}(\hat{\sigma}) \end{bmatrix} = \begin{bmatrix} .287 & .048 \\ .048 & .0176 \end{bmatrix} \\ \widehat{\text{se}}_{\hat{F}} &= \frac{\phi(\hat{\zeta}_e)}{\hat{\sigma}} \left[ \widehat{\text{Var}}(\hat{\mu}) + 2\hat{\zeta}_e \widehat{\text{Cov}}(\hat{\mu}, \hat{\sigma}) + \hat{\zeta}_e^2 \widehat{\text{Var}}(\hat{\sigma}) \right]^{1/2} \\ &= \frac{\phi(-2.000)}{.9778} \left[ .286 + 2 \times (-2.000) \times .047 + (-2.000)^2 \times .0176 \right]^{1/2} \\ &= .0225.\end{aligned}$$

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### Confidence Interval for the Device-A Lognormal Distribution $F(30,000)$ at $10^\circ\text{C}$

A 95% normal-approximation confidence interval based on the assumption that  $Z_{\log(\hat{F})} \sim \text{NOR}(0, 1)$  is

$$\begin{aligned}[F(t_e), \tilde{F}(t_e)] &= \left[ \frac{\hat{F}}{\hat{F} + (1 - \hat{F}) \times w}, \frac{\hat{F}}{\hat{F} + (1 - \hat{F})/w} \right] \\ &= \left[ \frac{.02281}{.02281 + (1 - .02281) \times w}, \frac{.02281}{.02281 + (1 - .02281)/w} \right] \\ &= [.0032, .14]\end{aligned}$$

where

$$\begin{aligned}w &= \exp\{(z_{(1-\alpha/2)} \widehat{\text{se}}_{\hat{F}}) / [\hat{F}(1 - \hat{F})]\} \\ &= \exp\{(1.96 \times .0225) / [.02281(1 - .02281)]\} = 7.232.\end{aligned}$$

This wide interval reflects sampling uncertainty when activation energy is unknown. The interval does not reflect model uncertainty. With given activation energy, the confidence intervals would be much narrower.

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### Checking Model Assumptions

It is important to check model assumptions by using residual analysis and other model diagnostics

- Define standardized residuals as

$$\exp \left\{ \frac{\log[t(x_i)] - \hat{\beta}_0 - \hat{\beta}_1 x_i}{\hat{\sigma}} \right\}$$

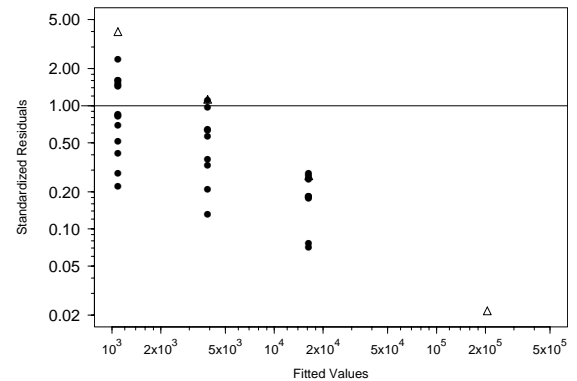
where  $t(x_i)$  is a failure time at  $x_i$ .

- Residuals corresponding to censored observations are called **censored** standardized residuals.
- Plot residuals versus the fitted values given by  $\exp(\hat{\beta}_0 + \hat{\beta}_1 x_i)$ .
- Do a probability plot of the residuals.

**Note:** For the Device-A data, these plots do not conflict with the model assumptions.

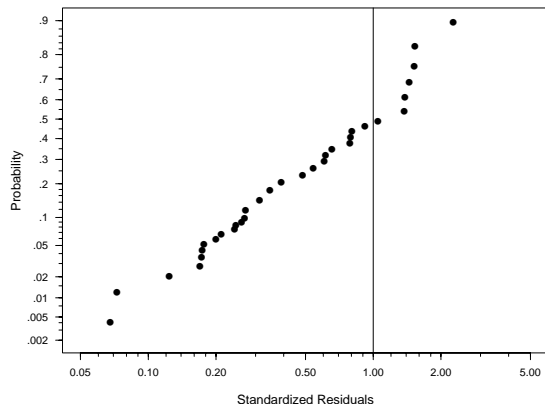
19 - 21

### Plot of Standardized Residuals Versus Fitted Values for the Arrhenius-Lognormal Log-Linear Regression Model Fit to the Device-A ALT Data



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### Probability Plot of the Residuals from the Arrhenius-Lognormal Log-Linear Regression Model fit to the Device-A ALT Data



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### Some Practical Suggestions

- Build on previous experience with similar products and materials.
- Use pilot experiments; evaluate the effect of stress on degradation and life.
- Seek physical understanding of cause of failure.
- Use results from physical failure mode analysis.
- Seek physical justification for life/stress relationships.
- Design tests to limit the amount extrapolation needed for desired inferences.
- See Nelson (1990).

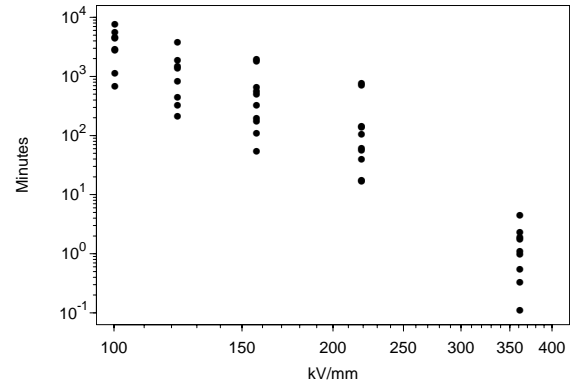
19 - 24

### Inferences from AT Experiments

- Inferences or predictions from ATs require important assumptions about:
  - Focused correctly on relevant failure modes.
  - Adequacy of AT model for extrapolation.
  - AT manufacturing testing processes can be related to actual manufacturing/use of product.
- Important sources of variability usually overlooked.
- Deming would call ATs **analytic studies** (see Hahn and Meeker 1993, *American Statistician*).

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### Breakdown Times in Minutes of a Mylar-Polyurethane Insulating Structure (from Kalkanis and Rosso 1989)



19 - 26

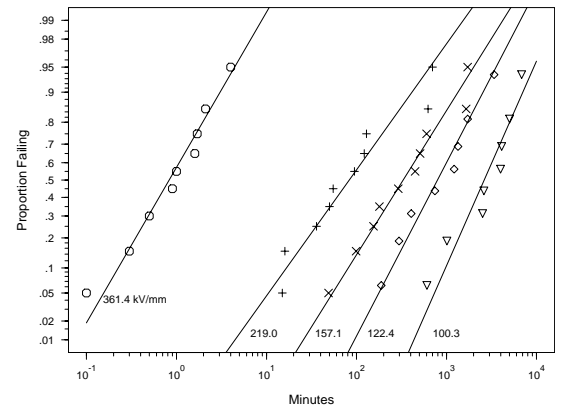
### Accelerated Life Test of a Mylar-Polyurethane Laminated Direct Current High Voltage Insulating Structure

- Data from Kalkanis and Rosso (1989)
- Time to dielectric breakdown of units tested at 100.3, 122.4, 157.1, 219.0, and 361.4 kV/mm.
- Needed to evaluate the reliability of the insulating structure and to estimate the life distribution at system design voltages (e.g. 50 kV/mm).
- Except for the highest level of voltage, the relation between log life and log voltage appears to be approximately linear.
- Failure mechanism probably different at 361.4 kV/mm.

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### Lognormal Probability Plot of the Individual Tests in the Mylar-Polyurethane ALT

$$\widehat{\Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right], \quad i = 100.3, \dots, 361.4$$



19 - 28

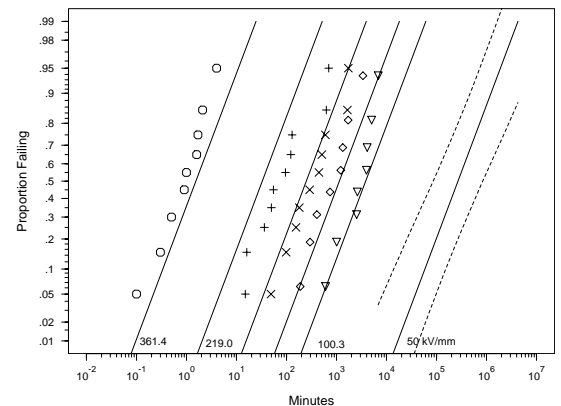
### Inverse Power Relationship-Lognormal Model

- The inverse power relationship-lognormal model is
 
$$F(t) = \Pr[T(\text{volt}) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \mu(x)}{\sigma} \right]$$
 where  $\mu(x) = \beta_0 + \beta_1 x$ , and  $x = \log(\text{Voltage Stress})$ .
- $\sigma$  assumed to be constant.

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### Lognormal Probability Plot of the Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data Including 361.4 kV/mm

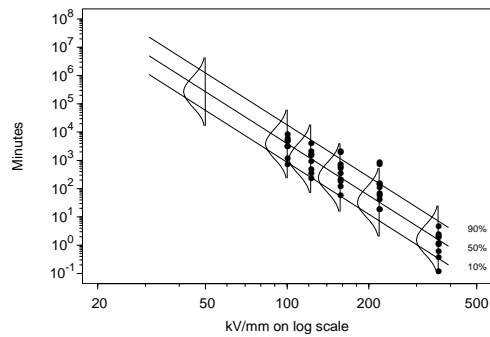
$$\widehat{\Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right], \quad i = 100.3, \dots, 361.4$$



19 - 30

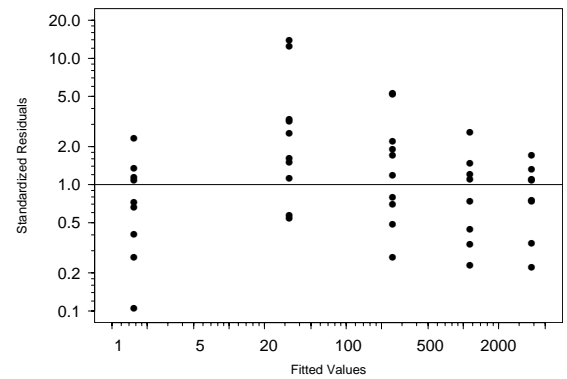
**Plot of Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data Including 361.4 kV/mm**

$$\log[\hat{t}_p(x)] = \hat{\mu}(x) + \Phi_{\text{nor}}^{-1}(p)\hat{\sigma}, \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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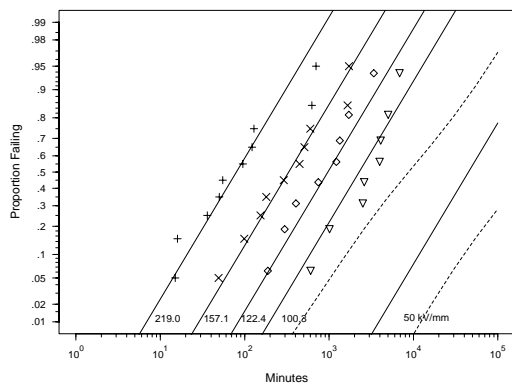
**Lognormal Plot of the Standardized Residuals versus  $\exp(\hat{\mu}(x))$  for the Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data with the 361.4 kV/mm Data**



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**Lognormal Probability Plot of the Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data W/O the 361.4 kV/mm Data**

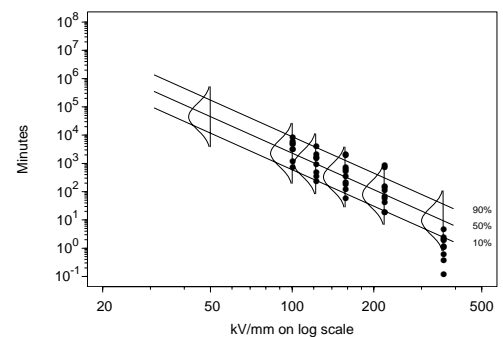
$$\widehat{\Pr}[T(\text{temp}) \leq t] = \Phi_{\text{nor}}\left[\frac{\log(t) - \hat{\mu}(x)}{\hat{\sigma}}\right], \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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**Plot of Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data (also Showing 361.4 kV/mm Data Omitted from the ML Estimation)**

$$\log[\hat{t}_p(x)] = \hat{\mu}(x) + \Phi_{\text{nor}}^{-1}(p)\hat{\sigma}, \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



19 - 34

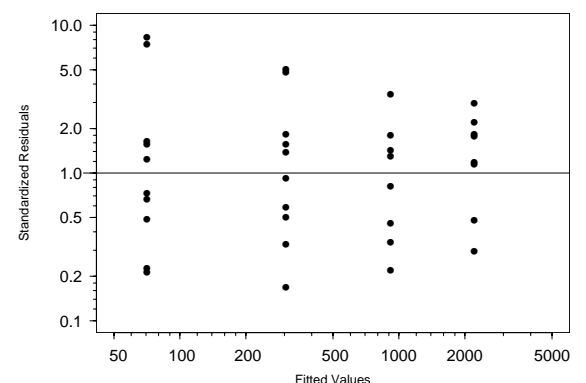
**Inverse Power Relationship-Lognormal Model ML Estimation Results for the Mylar-Polyurethane ALT Data**

Parameter	ML Estimate	Standard Error	95% Approximate Confidence Intervals	
			Lower	Upper
$\beta_0$	27.5	3.0	21.6	33.4
$\beta_1$	-4.29	.60	-5.46	-3.11
$\sigma$	1.05	.12	.83	1.32

The loglikelihood is  $\mathcal{L} = -271.4$ . The confidence intervals are based on the normal approximation method.

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**Lognormal Plot of the Standardized Residuals versus  $\exp(\hat{\mu})$  for the Inverse Power Relationship-Lognormal Model Fitted to the Mylar-Polyurethane Data W/O the 361.4 kV/mm Data**



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### Analysis of Interval ALT Data on a New-Technology IC Device

- Tests were run at 150, 175, 200, 250, and 300°C.
- Developers interested in estimating activation energy of the suspected failure mode and the long-life reliability.
- Failures had been found only at the two higher temperatures.
- After early failures at 250 and 300°C, there was some concern that no failures would be observed at 175°C before decision time.
- Thus the 200°C test was started later than the others.

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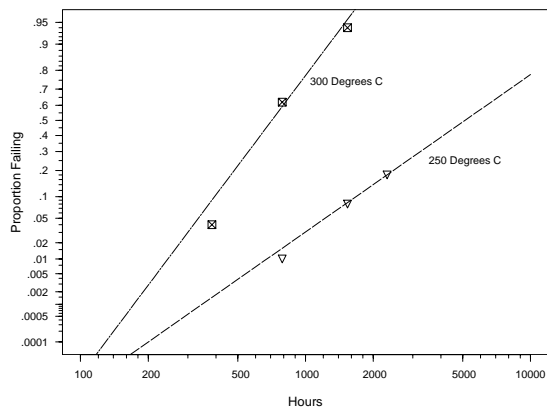
### New-Technology IC Device ALT Data

Hours		Status	Number of Devices	Temperature °C
Lower	Upper			
	1536	Right Censored	50	150
	1536	Right Censored	50	175
	96	Right Censored	50	200
384	788	Failed	1	250
788	1536	Failed	3	250
1536	2304	Failed	5	250
	2304	Right Censored	41	250
192	384	Failed	4	300
384	788	Failed	27	300
788	1536	Failed	16	300
	1536	Right Censored	3	300

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### Lognormal Probability Plot of the Failures at 250 and 300°C for the New-Technology Integrated Circuit Device ALT Experiment

$$\widehat{\Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right], \quad i = 250, 300$$



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### Individual Lognormal ML Estimation Results for the New-Technology IC Device

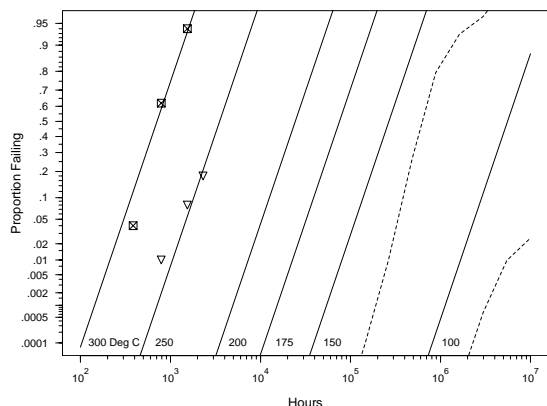
	Parameter	ML Estimate	Standard Error	95% Approximate Confidence Intervals	
				Lower	Upper
250°C	$\mu$	8.54	.33	7.9	9.2
	$\sigma$	.87	.26	.48	1.57
300°C	$\mu$	6.56	.07	6.4	6.7
	$\sigma$	.46	.05	.36	.58

The loglikelihood were  $\mathcal{L}_{250} = -32.16$  and  $\mathcal{L}_{300} = -53.85$ . The confidence intervals are based on the normal approximation method.

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### Lognormal Probability Plot Showing the Arrhenius-Lognormal Model ML Estimation Results for the New-Technology IC Device

$$\widehat{\Pr}[T(\text{temp}) \leq t] = \Phi_{\text{nor}} \left[ \frac{\log(t) - \hat{\mu}(x)}{\hat{\sigma}} \right], \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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### Arrhenius-Lognormal Model ML Estimation Results for the New-Technology IC Device

Parameter	ML Estimate	Standard Error	95% Approximate Confidence Intervals	
			Lower	Upper
$\beta_0$	-10.2	1.5	-13.2	-7.2
$\beta_1$	.83	.07	.68	.97
$\sigma$	.52	.06	.42	.64

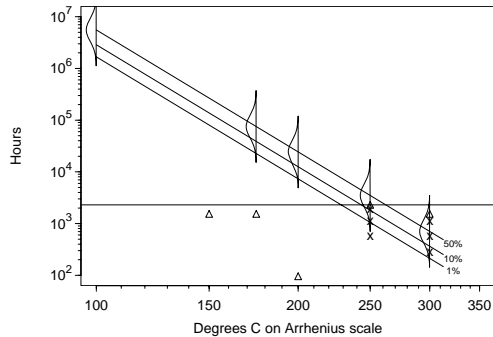
The loglikelihood is  $\mathcal{L} = -88.36$ .

Comparing the constrained and unconstrained models  $\mathcal{L}_{\text{unconst}} = \mathcal{L}_{250} + \mathcal{L}_{300} = -86.01$  and for the constrained model,  $\mathcal{L}_{\text{const}} = -88.36$ . The comparison has just one degree of freedom and  $-2(-88.36 + 86.01) = 4.7 > \chi^2_{(.95,1)} = 3.84$ , again indicating that there is some lack of fit in the constant- $\sigma$  Arrhenius-lognormal model.

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### Arrhenius Plot Showing ALT Data and the Arrhenius-Lognormal Model ML Estimation Results for the New-Technology IC Device.

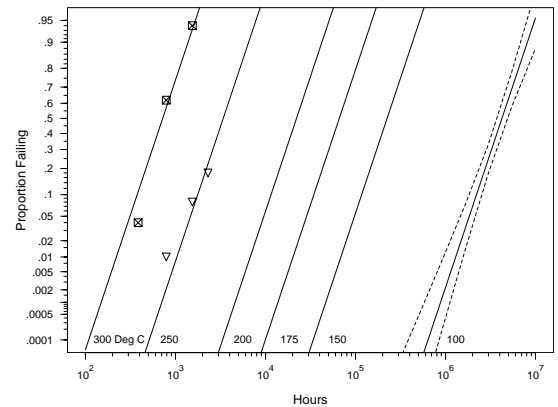
$$\log[\hat{t}_p(x)] = \hat{\mu}(x) + \Phi_{\text{nor}}^{-1}(p)\hat{\sigma}, \quad \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x$$



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### Lognormal Probability Plot Showing the Arrhenius-Lognormal Model ML Estimation Results for the New-Technology IC Device with Given $E_a = .8$

$$\widehat{\Pr}[T(\text{temp}) \leq t] = \Phi_{\text{nor}}\left[\frac{\log(t) - \hat{\mu}(x)}{\hat{\sigma}}\right], \quad \hat{\mu}(x) = \hat{\beta}_0 + E_a x$$



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### Pitfall 1: Multiple (Unrecognized) Failure Modes

- High levels of accelerating factors can induce failure modes that would not be observed at normal operating conditions (or otherwise change the life-acceleration factor relationship).
- Other failure modes, if not recognized in data analysis, can lead to incorrect conclusions.
- Suggestions:
  - ▶ Determine failure mode of failing units.
  - ▶ Analyze failure modes separately.

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### Pitfall 2: Failure to Properly Quantify Uncertainty

- There is uncertainty in statistical estimates.
- Standard statistical confidence intervals quantify uncertainty arising from **limited data**.
- Confidence intervals **ignore model uncertainty** (which can be tremendously amplified by extrapolation in Accelerated Testing).
- Suggestions:
  - ▶ Use confidence intervals to quantify statistical uncertainty.
  - ▶ Use sensitivity analysis to assess the effect of departures from model assumptions and uncertainty in other inputs.

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### Pitfall 3: Multiple Time Scales

- Composite material
  - ▶ Chemical degradation over time changes material ductility.
  - ▶ Stress cycles during use lead to initiation and growth of cracks.
- Incandescent light bulbs
  - ▶ Filament evaporates during burn time.
  - ▶ On-off cycles induce thermal and mechanical shocks that can lead to fatigue cracks.
- Inkjet pen
  - ▶ Real time (corrosion)
  - ▶ Characters or pages printed (ink supply, resistor degradation).
  - ▶ On/off cycles of a print operation (thermal cycling of substrate and printhead lamination).

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### Dealing with Multiple Time Scales

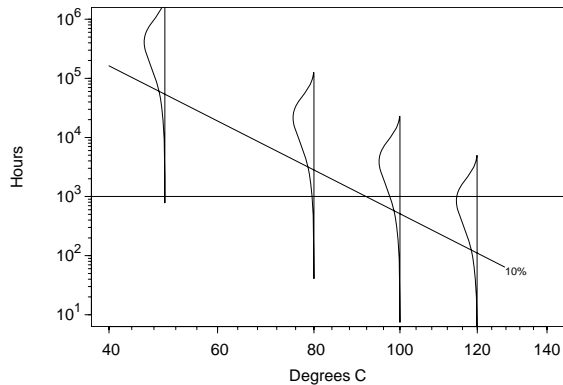
Suggestions:

- Need to use the appropriate time scale(s) for evaluation of each failure mechanism.
- With multiple time scales, understand ratio or ratios of time scales that arise in actual use.
- Plan ATs that will allow effective prediction of failure time distributions at desired ratio (or ratios) of time scales.

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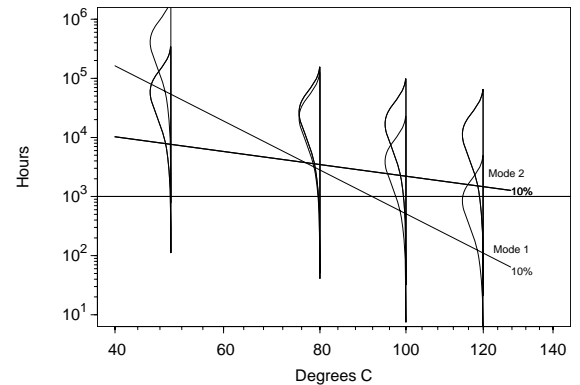


### Temperature-Accelerated Life Test for an IC Device



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### Unmasked Failure Mode with Lower Activation Energy for an IC Device



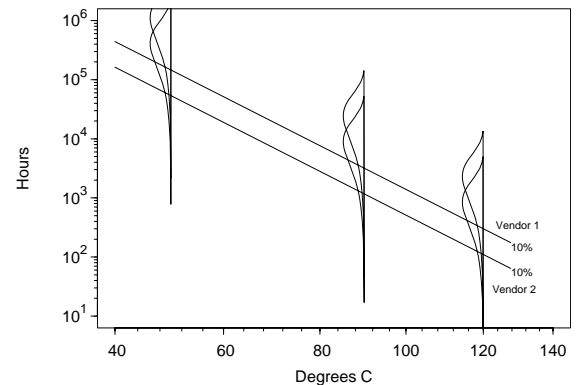
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### Pitfall 4: Masked Failure Mode

- Accelerated test may focus on one known failure mode, masking another!
- Masked failure modes may be the first one to show up in the field.
- Masked failure modes could dominate in the field.
- Suggestions:
  - ▶ Know (anticipate) different failure modes.
  - ▶ Limit acceleration and test at levels of accelerating variables such that each failure mode will be observed at two or more levels of the accelerating variable.
  - ▶ Identify failure modes of all failures.
  - ▶ Analyze failure modes separately.

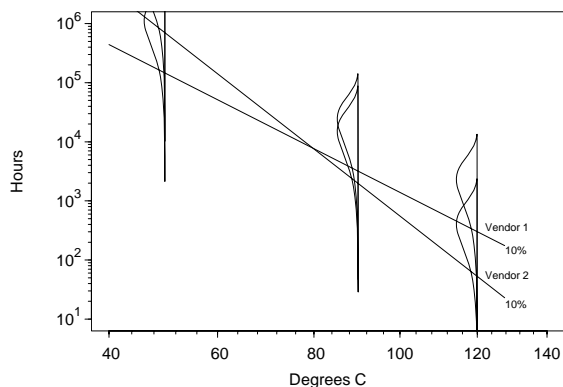
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### Comparison of Two Products I Simple Comparison



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### Comparison of Two Products II Questionable Comparison



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### Pitfall 5: Faulty Comparison

- It is sometimes claimed that Accelerated Testing is not useful for predicting reliability, but is useful for comparing alternatives.
- Comparisons can, however, also be misleading.
- Beware of comparing products that have different kinds of failures.
- Suggestions:
  - ▶ Know (anticipate) different failure modes.
  - ▶ Identify failure modes of all failures.
  - ▶ Analyze failure modes separately.
  - ▶ Understand the physical reason for any differences.

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**Pitfall 6: Acceleration Factors  
Can Cause Deceleration!**

- Increased temperature in an **accelerated** circuit-pack reliability audit resulted in fewer failures than in the field because of lower humidity in the **accelerated** test.
- Higher than usual use rate of a mechanical device in an accelerated test inhibited a corrosion mechanism that eventually caused serious field problems.
- Automobile air conditioners failed due to a material **drying out** degradation, lack of use in winter (not seen in continuous accelerated testing).
- Inkjet pens fail from infrequent use.
- **Suggestion:** Understand failure mechanisms and how they are affected by experimental variables.

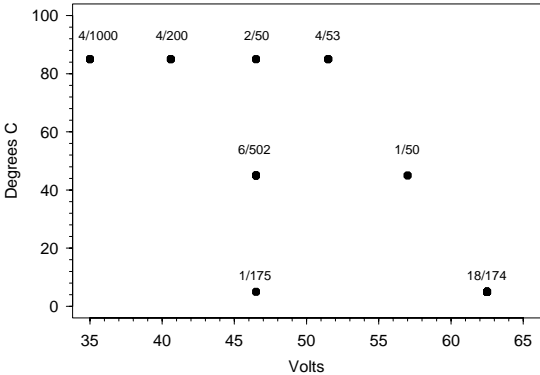
**Pitfall 7: Untested Design/Production Changes**

- Lead-acid battery cell designed for 40 years of service.
- New epoxy seal to inhibit **creep** of electrolyte up the positive post.
- Accelerated life test described in published article **demonstrated** 40 year life under normal operating conditions.
- 200,000 units in service after 2 years of manufacturing.
- First failure after 2 years of service; third and fourth failures followed shortly thereafter.
- Improper epoxy cure combined with charge/discharge cycles hastened failure.
- Entire population had to be replaced with a re-designed cell.

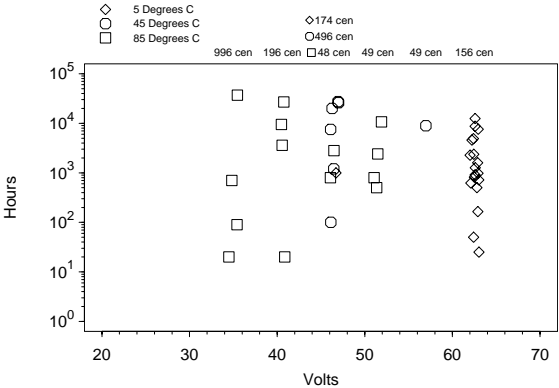
**Temperature/Voltage ALT Data on  
Tantalum Electrolytic Capacitors**

- Two-factor ALT
- Non-rectangular unbalanced design
- Much censoring
- The Weibull distribution seems to provide a reasonable model for the failures at those conditions with enough failures to make a judgment.
- Temperature effect is not as strong.
- Data analyzed in Singpurwalla, Castellino, and Goldschen (1975)

**Tantalum Capacitors ALT Design Showing Fraction  
Failing at Each Point**

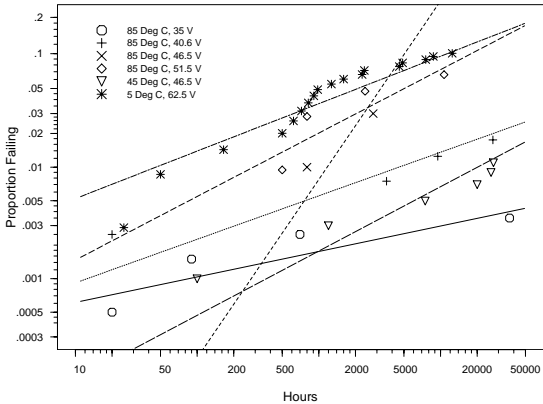


**Scatter Plot of Failures in the Tantalum Capacitors  
ALT Showing Hours to Failure Versus Voltage with  
Temperature Indicated by Different Symbols**



**Weibull Probability Plot for the Individual Voltage and  
Temperature Level Combinations for the Tantalum  
Capacitors ALT, with ML Estimates of Weibull cdfs**

$$\widehat{Pr}[T(\text{temp}_i) \leq t] = \Phi_{\text{sev}} \left[ \frac{\log(t) - \hat{\mu}_i}{\hat{\sigma}_i} \right]$$



## Tantalum Capacitors ALT Weibull/Arrhenius/Inverse Power Relationship Models

Model 1:  $\mu(x) = \beta_0 + \beta_1 x_1 + \beta_2 x_2$

Model 2:  $\mu(x) = \beta_0 + \beta_1 x_1 + \beta_2 x_2 + \beta_3 x_1 x_2$

where  $x_1 = \log(\text{volt})$ ,  $x_2 = 11605/(\text{temp K})$ , and  $\beta_2 = E_a$ .

- Coefficients of the regression model are highly sensitive to whether the interaction term is included in the model or not (because of the nonrectangular design with highly unbalanced allocation).
- Data provide no evidence of interaction.
- Strong evidence for an important voltage effect on life.

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## Tantalum Capacitor ALT Weibull-Inverse Power Relationship Regression ML Estimation Results

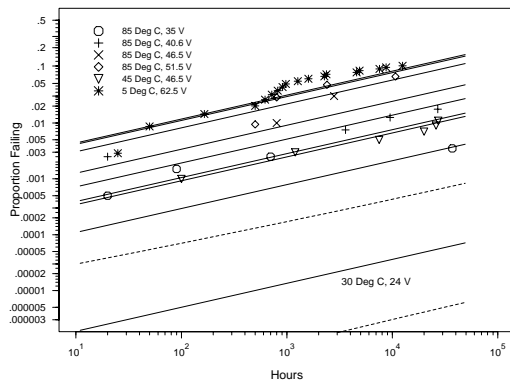
	Parameter	ML Estimate	Standard Error	95% Approximate Confidence Interval	
				Lower	Upper
Model 1	$\beta_0$	84.4	13.6	57.8	111.
	$\beta_1$	-20.1	4.4	-28.8	-11.4
	$\beta_2$	.33	.19	-.04	.69
	$\sigma$	2.33	.36	1.72	3.16
Model 2	$\beta_0$	-78.6	109.0	-292.3	135.1
	$\beta_1$	19.9	26.7	-32.5	72.35
	$\beta_2$	5.13	3.3	-1.35	11.6
	$\beta_3$	-1.17	.80	-2.8	.40
	$\sigma$	2.33	.36	1.72	3.16

Loglikelihoods  $\mathcal{L}_1 = -539.63$  and  $\mathcal{L}_2 = -538.40$

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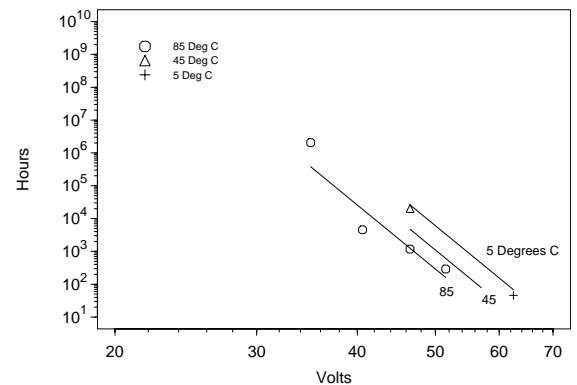
## Weibull Multiple Probability Plot of the Tantalum Capacitor ALT Data Arrhenius-Inverse Power Relationship Weibull Model (with no interaction)

$$\widehat{\Pr}[T(\text{temp}) \leq t] = \Phi_{\text{sev}} \left[ \frac{\log(t) - \hat{\mu}(x)}{\hat{\sigma}} \right], \hat{\mu}(x) = \hat{\beta}_0 + \hat{\beta}_1 x_1 + \hat{\beta}_2 x_2$$



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## ML Estimates of $t_{0.01}$ for the Tantalum Capacitor Life Using the Arrhenius-Inverse Power Relationship Weibull Model



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## Other Topics in Chapter 19

Discussion of

- Highly accelerated life tests (HALT).
- Environmental stress and STRIFE **testing**.
- Burn-in.
- Environmental stress **screening**.

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